

EE539: ANALOG INTEGRATED CIRCUIT DESIGN.

Nagendra Krishnapura(nagendra@iitm.ac.in)

18 JANUARY 2006

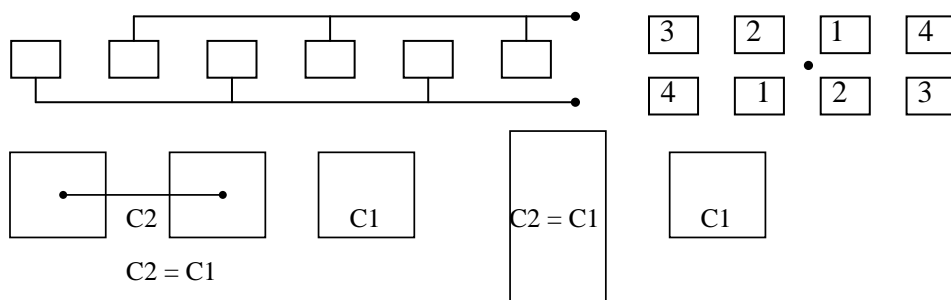
Mismatch in components.

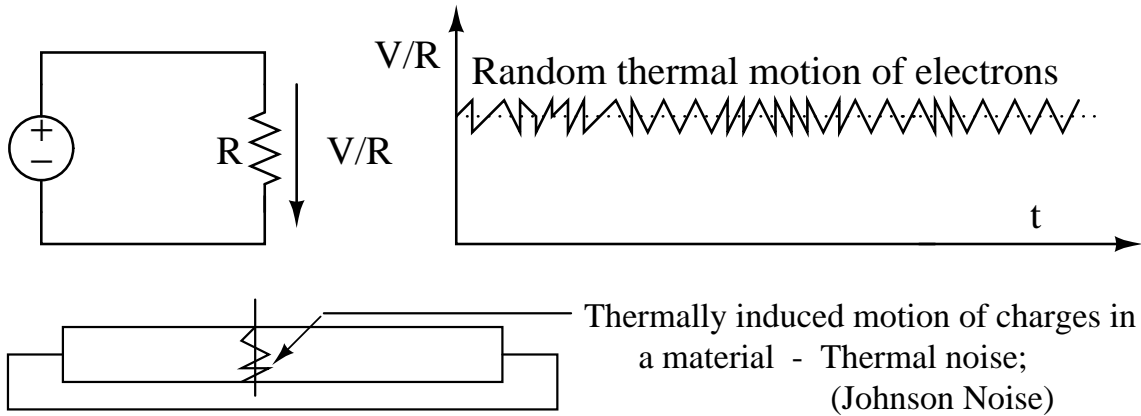
➔ Systematic mismatch :

- ◇ Predictable variations in component values.
- ◇ Gradients across the chip.
- ◇ Fabrication gradients.
- ◇ Temperature gradients.
- ◇ Usually assumed to be linear.

➔ Common centroid arrangement.

- ◇ The components that need to be matched must have a common centroid
- ◇ But leads to a more complicated layout.





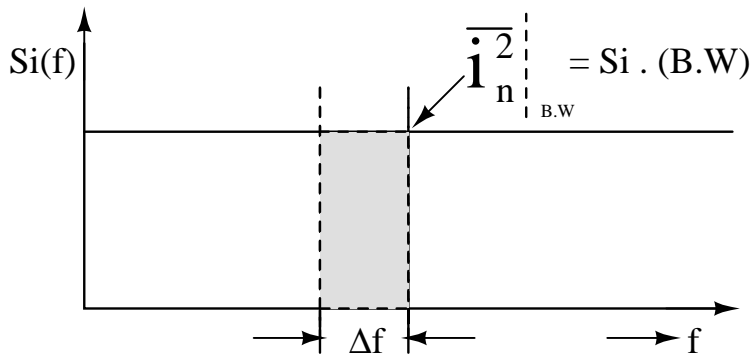
- ◇ $C = C'_A A + C_P \cdot P$;
- ◇ $C_P \Rightarrow$ fringe capacitance per unit length.
- ◇ Dummy devices for identical surroundings.
- ◇ Ratios = no. of identical units.

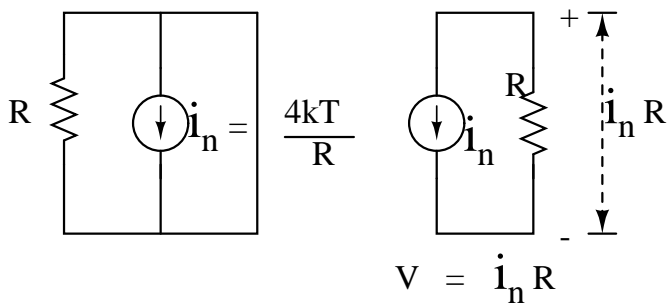
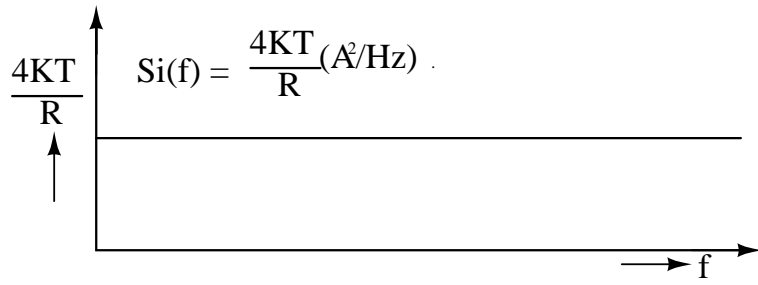
Noise : Random noise variations in the current(voltage) due to the discrete ness of the current and their random motion.

Thermal noise current $i(t)$; is uncorellated from instant to instant and from component to component.

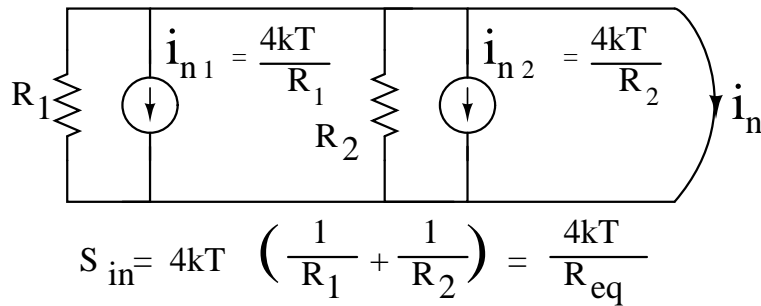
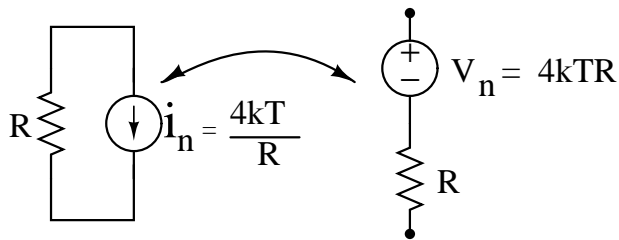
$i_n(t)$ = Value at each instant is random white noise.
(i.e.... Power spectral density is uniform.)

Resistance : Thermal noise current.





$$S_v = \frac{4kT}{R} R^2 = 4kTR$$



Mean square noise current in the range (f_1, f_2) .

$$= \int_{f_1}^{f_2} Si(f) df \frac{4kT}{R} (f_2 - f_1)$$

$$R.M.S = \sqrt{\frac{4kT}{R} (f_2 - f_1)}.$$